ROHINI COLLEGE OF ENGINEERING & TECHNOLOGY Unit III

SEMICONDUCTING MATERIALS

CONTENTS

3.5. HALL EFFECT:

STATEMENT

When a magnetic field (B) is applied perpendicular to a current carrying conductor or semiconductor a potential difference (electric field) is developed inside the conductor in a direction perpendicular to both current and magnetic field. This phenomenon is known as Hall Effect and the voltage thus generated is called Hall voltage

THEORY

3.5.1.Hall effect in n- type semiconductor

Let us consider a n-type semiconductor material in the form of rectangular slab. In such a material current flows in X –direction and magnetic field B applied in Z- direction. As a result, Hall voltage is developed along Y –direction as shown in figure



Fig 3.5.1-Hall Effect in N type semiconductor

Since the direction of current is from left to right the electrons moves from right to left. When a magnetic field is applied the electrons are moving towards the bottom of the semi conductor.



Fig 3.5.2-Hall Effect

Lorentz force= -e E_H ---(1)

Magnetic deflecting force = - Bev ---(2)

At equilibrium

-e $E_{H} = -$ Bev $E_{H} =$ Bv ---(3)

We know the current density J_x in the X- direction is

 $J_x = -ne v$ v = - J_x / ne ----(4)

Substituting equation (4) in equation (3)

we get $E_{\rm H} = - B J_{\rm x} / ne$ -----(5)

$$E_{\rm H} = R_{\rm H} \, . \, J_{\rm x} \, . \, B$$
 -----(6)

Where R_H is known as the Hall co –efficient, is given by $R_H = -(1 / n_e)$ (7)

The negative sign indicates that the field is developed in the negative Y -direction.

3.5.2 Hall effect in p -type semiconductor

Let us consider a p –type semiconducting material for which the current is passed along X – direction from left to right and magnetic field is applied along Z – direction as shown in fig. since PH 3254-PHYSICS FOR ELECTRONICS ENGINEERING

the direction of current is from left to right, the holes will also move in the same direction as shown in fig.



Fig 3.5.3-Hall Effect in P type semiconductor

Now due to magnetic field applied the holes moves towards downward direction with velocity v and accumulates at the face (1). A potential difference is established between face (1) and (2) in the positive Y - direction.

Here, the force due to potential difference = $-e E_{H}$ (8)

Force due magnetic field = Bev-----(9)

At equilibrium equation (1) = equation (2) $E_{H} = Bev$

 $E_{\rm H} = Bv - (10)$

We know the current density Jx in the X- direction is

 $J_x = nh ev$ $v = J_x / n_h e ----- (11)$

Substituting equation (4) in equation (3) we get

$$E_{H} = B J_{x} / n_{h} e$$
$$E_{H} = R_{H} . J_{x} . B$$

Where RH is known as the Hall co –efficient, is given by $R_H = (1 / n_h e)$ The positive sign indicates that the field is developed in the positive Y –direction

3.5.3.Hall coefficient in terms of hall voltage

ROHINI COLLEGE OF ENGINEERING & TECHNOLOGY If the thickness of the sample is t and the voltage developed is VH, thenHall voltage

VH = EH .t

Substituting equation (6) in equation (13), we have

VH = RH Jx B .t

b is the width of the sample then

Current density = Jx = Ix / bt

There fore

 $V_{\rm H} = RH B .t Ix / bt$

 $V_{\rm H} = RH B Ix / b$ $R_{\rm H} = V_{\rm H} b / I_{\rm x} B$

This is the expression for Hall coefficient.

3.5.4.EXPERIMENTAL DETERMINATION OF HALL EFFECT

A semiconducting material is taken in the form of a rectangular slab of thickness t and breadth b. A suitable current I_x ampere is passed through this sample along X- axis by connecting it to a battery



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Now a semiconductor is placed in a magnetic field . A voltage is developed in the specimen which can be measured by using the voltmeter connecting with the specimen.

Then by using the formula

Hall coefficient,
$$R_H = \frac{V_H b}{Ix B}$$

Hall coefficient can be calculated.

2.6.5.APPLICATIONS OF HALL EFFECT

- It is used to determine whether the material is p-type or n-type semiconductor. (ie) if RH is negative then the material n-type. If the RH is positive then the materialp-type.
- It is used to find the carrier concentration
- It is used to find the mobility of charge carriers μe, μh. It is used to find the sign of the current carrying charges.
- From the hall coefficient, carrier concentration and mobility can bedetermined.

